

Remote-controlled fabrication of 2D heterostructuren

December 20, 2022

Report by: B. Klein Ikkink

Supervised by: S. Bhattacharyya, LION F. Galli, LION

Foreword

Add the foreword

Abstract

Create the abstract

Contents

1	Introduction	1
2	Project definition	2
	2.1 Research question	2
	2.2 Research goal	2
3	Background Sackground	3
	3.1 van der Waals Heterostuctures	3
	3.2 Fabrication of van der Waals Heterostructures: Stamping	3
	3.3 Vibration isolation	3
	3.4 Criteria	5
4	Methods & Results	5
	4.1 Stand design	5
	4.2 Mask design	7
	4.3 Sample holder design	8
	4.4 Base stage automisation	8
	4.5 Stage calibration	9
	4.6 Software	9
	4.6.1 Architecture	9
	4.6.2 Frontend	9
	4.6.3 Middleware	9
	4.6.4 Backend	11
	4.6.5 Forbidden areas	11
5	5 Conclusion	12
6	5 Discussion	12
A	A Programming terms	14
В	B Backend base classes	16
To	Codo list	23

Used abbreviations

- LION: Leiden Institute Of Physics
- VDWSF: Van Der Waals Stacking Facility
- FMD : Fine Mechanical Department
- ELD : Electronics Department
- TUI : Terminal User Interface (differend from CLI in the sense that the user doesn't directly interact with the command line)
- GUI: Graphical User Interface
- SDK: Software Development Kit
- DAS: Domain Applied Science

pagina nummering pas hier beginnen, voorgaande in romeinse nummer-

ing

1 Introduction

The discovery of graphene in 2004, awarded the Nobel Prize in Physics in 2010, has led to a completely new field of research based on 'atomically thin materials', materials of a few atomic layers thick (2D materials). Recently, the focus of the research area has shifted to fabricating completely new structures by stacking different atomically thin materials 'Van Der Waals Heterostructures'. Atomic thin materials can consist of metals, semiconductors, insulators, ferromagnets, superconductors, etc., combining these materials is a route to developing useful devices [Geim and Grigorieva].

Rephrase the text so it isn't flagged a plagiaat

Recently, a new research group was started under Principle Investigator Dr. Semonti Bhattacharyya who is an expert in fabricating and characterizing Van Der Waals Heterostructures and 2D materials and who recently started her new laboratory at LION, the Van Der Waals Stacking Facility (VDWSF). This project will focus on the efficient and accurate fabrication and imaging of the Van Der Waals Heterostructures and will be carried out by the Van Der Waals stacking lab at the Leiden Institute of Physics (LION). LION is one of the oldest physics research institutes in the Netherlands. The research performed at Leiden Institute of Physics covers a broad spectrum of topics, from cosmology to condensed matter physics, from quantum computers to new systems such as Van Der Waals Heterostacks. Research at LION is largely fundamental and curiosity-driven but also with an eye toward societal value.

This project will take place at the Leiden Institute of Physics (LION), which is one of the oldest physics institutes in the Netherlands. Research at the Leiden Institute of Physics covers a broad spectrum of subjects, ranging from cosmology to condensed matter physics, from the physics of jamming in granular materials to quantum computation, from protein folding to superconductivity and novel systems like van der Waals materials. Recently a new research group has been appointed to Semonti Bhattacharyya who is an expert in fabrication and characterisation of van der Waals and 2D materials and who has recently started to setup her new laboratory at LION, the Van Der Waals Stacking Facility (VDWSF). This project will focus on the efficient and accurate fabrication and imaging of the Van Der Waals Heterostructures with adaptability in mind to make the instrument more flexible and fit future research projects.

2 Project definition

Presently a commercial setup for fabricating 2D Hetero-stacks is used in the Van Der Waals Stacking Facility (VDWS) at lion. This commercial setup is prone to vibrations and has an inferior-quality microscope, wich makes it difficult to clearly identify small 2D material. Furthermore, the laboratory has a vibration level slightly above VC-C [Isolation]. For these reasons a new setup will be developed that should be less sensitive to mechanical vibrations. This setup is focused on improved rigidity, accuracy and flexibility compared to the commercially available and previous versions. The setup will be based on a commercial (Olympus BXFM) optical microscope, but to reach this goal a custom microscope stand, sample holder, mask holder and software have to be developed.

2.1 Research question

What components and control techniques should be used to make the stacking setup as least susceptible to vibration as possible and controllable at the sub-micrometer scale while producing clear images with an optical microscope?

2.2 Research goal

Building a stacking setup that is as least susceptible to vibration as possible where the base x-y-z stages move with resolution on the micrometer scale and the mask x-y-z stages on the nanometer scale, which can be remotely controlled, while being able to capture clear images with an optical microscope.

3 Background

Over the past decade, research into two-dimensional (2D) materials and van der Waals heterostructures has opened up a world of possibilities for the development of new technologies. 2D materials, such as graphene and hexagonal boron nitride, are atomically thin and have unique electrical, optical, and mechanical properties that make them interesting for a variety of applications.

3.1 van der Waals Heterostuctures

Van der Waals heterostructures are composed of two or more 2D materials that are stacked together and can be used to create electronic and optoelectronic nano devices. This research has enabled the development of a wide range of technologies, including flexible electronics, high-speed transistors, and ultra-sensitive sensors. The promise of 2D materials and van der Waals heterostructures is that they can be used to create devices that are faster, more efficient, and more reliable than existing technologies [Geim and Grigorieva].

3.2 Fabrication of van der Waals Heterostructures: Stamping

The stamping process is a method used to fabricate van der Waals heterostructures. This process involves the transfer of 2D crystals onto a substrate by pressing them together with a stamp so the van der Waals forces between the layers become strong enough to hold the layers together.

The general stamping procedure is as follows:

- 1. The 2D material flakes are plased on top of the substrate
- 2. The operator looks for suitable flakes to use for the stamping
- 3. The operator places the stamp on top of the 2D material flake and changes the sample temperature to stick the flake to the stamp
- 4. The stamp with the flake is positioned above the second 2D material flake on the substrate
- 5. The operator places the stamp on top of the second 2D material flake and changes the sample temperature to release the flake from the stamp
- 6. The operator finds a new suitable flake to place on top of the created stack and repeats the process

This process consists of serval time consuming steps, such as finding suitable flakes, placing the flakes on the stamp and substrate, and changing the sample temperature. The aim of this project is to automate the process of stamping to reduce the time needed to fabricate a stack and to increase the accuracy of the process.

3.3 Vibration isolation

Bij het ontwerpen van de stand van de microscoop moet sterk rekening gehouden worden met de rigiditeit en eigenfrequensie van de opstelling. Bij commercieel verkrijgkbare stacking opstellingen is een faseverschil tussen trilling door het monster, masker en camera een bekend en veel voorkomend probleem, dit heeft als effect dat de uitlijning van flakes en het stapelen bemoeilijkt worden en de kans op beschadigen van de flake aanzienlijk groter is.

Het doel van het in house fabriceren van de microscoop stand is dan ook het behalen va een betere performance op het gebied van trillingsisolatie en rigiditeit tegenover commercieel verkrijgbare standaarden.

Bij het bestuderen van trillings respons van een opstelling kan er gekeken worden naar kracht gedreven trilling (er word een periodieke kracht uitgeoefend op een vast punt op het instrument) of er kan gekeken worden naar amplitude gedreven trilling (trillen van het oppervlak onder het instrument). Het is belangrijk

citaat invoegen

VAN GRAFEEI

aFBEELD

EN HEXAG-

ONAAL

BOORNI TRIDE

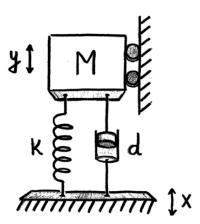
INVOE-

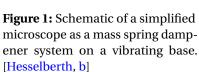
GEN

Stuk invoegen over verandering in fase plot (bode)

bij ver-

om het onderscheid tussen beide methodes te maken omdat deze wiskundig verschillend worden beschreven en ook anders dynamisch gedrag vertonen [Hesselberth, a], in het geval van dit project zal er gekeken worden naar een sterk gesimplificeerd model voor een amplitude gedreven trilling (zie figuur 1.





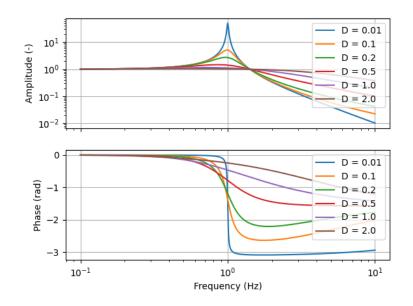


Figure 2

Door de opstelling te zien als een gedempt massa veer system (zie figuur 1)kan met regeltechniek theorie het verwachte dynamische gedrag benadert worden. Om de berekeningen te versimpelen word de opstelling verdeelt in 2 inertiaalsetelsels, stelsel Y met coorinaat y voor de uitwijking van de massa m met respect tot de evenwichtspositie van de massa en X met coordinaat x voor de uitwijking van de basis met respect tot de evenwichtspositie. Omdat het gedrag als functie van tijd voor dit systeem niet van belang alleen de overdracht als functie van frequenstie kan er gekeken worden naar de overdracht van het systeem in het Laplace domein. Het model bestaat uit de gecombineerde krachten balans in de Z richting zoals beschreven in formule 1. Door de balans vervolgens te transformeren naar het Laplace domein en te herordenen kan de overdrachtsfunctie zoals beschreven in formule 3 verkregen worden.

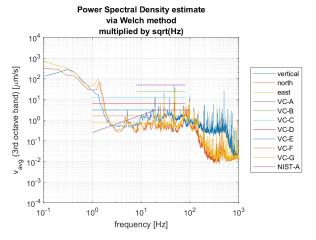
$$m\frac{\mathrm{d}^2 y}{\mathrm{d}t^2} + d\frac{\mathrm{d}y}{\mathrm{d}t} + ky = d\frac{\mathrm{d}x}{\mathrm{d}t} + kx \tag{1}$$

$$\omega_0 = \sqrt{\frac{k}{m}}; \quad D = \frac{d}{\sqrt{2mk}}; \quad f = \frac{\omega}{\omega_0}$$
 (2)

$$H = \frac{Y}{X} = \frac{dj\omega + k}{-m\omega^2 + dj\omega + k} = \frac{\omega_0^2 + 2jD\omega_0^2 f}{\omega_0^2 + 2jD\omega_0^2 f - \omega^2 f^2}$$
(3)

$$A = \frac{\sqrt{1 + (2Df)^2}}{(1 - f^2)^2 + (2Df)^2}; \quad \phi = \arctan\left(\frac{-2Df^3}{1 - f^2 + (2Df)^3}\right)$$
(4)

Zoals te zien in formulde 3 te zien is zal de amplitude oneindig naderen wanneer het systeem geen dempingsfactor heeft. Het instrument zelf zal geen demping hebben maar geplaats worden op een actieve vibratie isolatie tafel, voor correcte werking is het van belang dat de resonantiefrequenie van het instrument buiten de doorgelaten band van de actieve tafel valt. Voor de gebruikte active demper is dit 90% vanaf 2 Hz en 99% vanaf 10 Hz [DVI]



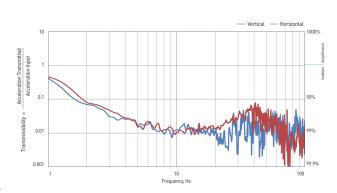


Figure 3: Measured vibration data in the Van der Waals Stacking Facility laboratory on the position of the stacking instrumentation. By J. Scheffer

Figure 4

3.4 Criteria

Door het analyseren von de workflow van handmatige en gemotoriseerde commerciele stamping opstellingen in combinatie met literatuur studie is een lijst aan minimale eisen opgesteld waar het te ontwikkelen instrument aan moet voldoen.

1. Mask holder

- (a) The mask should be motorized and able to move in the x, y and z direction with a resolution of > 30 nm.
- (b) The pitch of the mask should be able to be adjusted with a resolution of $> 0.05^{\circ}$.
- (c) The yaw of the mask should be able to be adjusted with a resolution of $> 0.05^{\circ}$, with a minimum range of 180° .

2. Sample holder

- (a) The sample holder should be able to hold a minimum of 2 samples.
- (b) The sample should be able to heat with a ramp speed of $2.0 50.0^{\circ} C/s$
- (c) The sample should be able to cool with a ramp speed of $-0.1 30.0^{\circ} C/s$

3. Microscope & stand

- (a) Due to the fact that the VDWSF laboratry has problems with external vibrations (see 3 the microscope stand should be as rigid as possible to make the instrument behave like one rigid body instead of a system of multiple bodies.
- (b) The microscope should a 20x objective with correction collar to be able to focus on the sample through the mask holder glass slide.

4 Methods & Results

4.1 Stand design

Voor het fabriceren van stacks is het belangrijk dat de opstelling zo min mogenlijk beinvloed word door trillingen uit de omgeving. . Om deze reden is er voor gekozen om in samenwerking met LION FMD een aantal uitwijkings simulaties uit te voeren om een inschatting te kunnen maken over de maximale uitwijking onder een statische kracht van de microscoop stand.

uitzoeker aan welk vc norm wij willer voldoen

betekenis van NIST A norm

uitzoeker

grafiek

Het complete instrument bestaat uit verschillende aspecten die in de volgende hoofdstukken behandelt zullen worden. Voor een overzicht van de gebruikte hard- en software componenten zie 13.

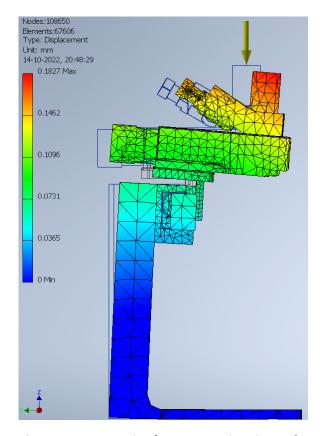


Figure 5: 100 N pressing force on a static point on the microscope. To reduce displacement a 30mm fillet was added between the base-plate and stand, reducing the maximum displacent to $183\mu m$. By R. Stoelwinder

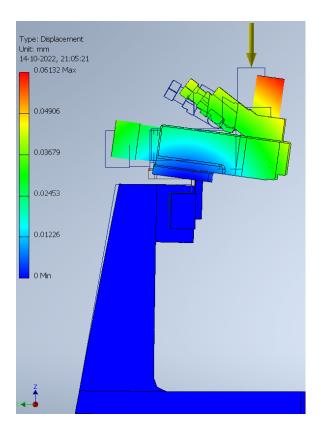


Figure 6: 100N pressing force on a static point on the microscope head. To reduce the the maximum displacement the thickness of the base-plate is increased from 20mm to 50mm, reducing the maximum displacement to 50μ m. By R. Stoelwinder

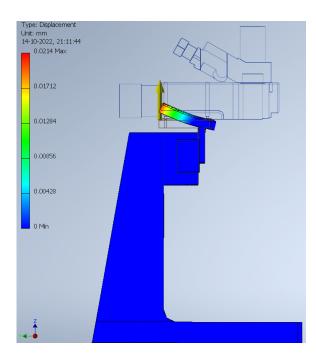


Figure 7: 100N pulling force on a static point on the corner plate causing a $21\mu m$ displacement. By R. Stoelwinder

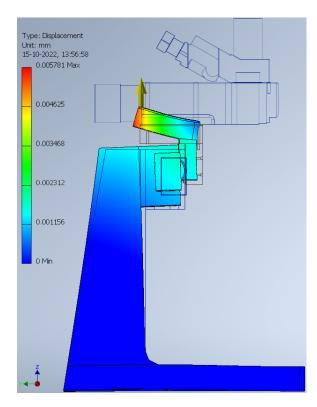


Figure 8: 100 N pulling force on a static point on the corner-plate. To reduce the maximum displacement the thickness of the corner plate is increased from 20mm to 40mm, reducing the maximum displacement to 5μ m. By R. Stoelwinder

4.2 Mask design

the mask consists of two major parts: the mask holder wich holds the stamping polymer and the stages wich are used to position the mask above the sample

For the mask holder



Figure 9: The mask holder schematic. By R. Stoelwinder

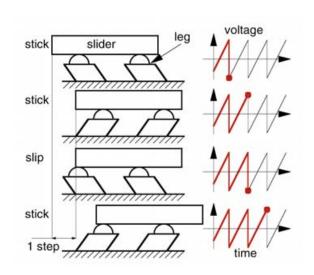


Figure 10: Operating principle of a slip-stick actuator mechanism [Mazerolle et al.]

CAD schema van de mask holder invoegen

4.3 Sample holder design

de hoofdtaak van de samplehouder is zoals de naam zegt het in positie houden van het monster waarmee gewerkt word (in dit geval een waver). Net zoals de rest van het instrument is het van belang om de sample houder zo rigide mogenlijk te maken om ervoor te zorgen dat de trillingen van de masker en de camera in fase blijven.

Tijdens de duur van dit project is het eerste prototype van de samplehouder gefabriceerd en zijn de plannen voor het vervolg ontwerp gemaakt. Het prototype (zie figuur 9) bestaat uit 3 onderdelen: Het sample bed, isolatielaag en de dump cilinder. Het sample bed bevat de benodigde componenten om de het sample naar op gewilde temperatuur tussen 0 en 200 graden C krijgen, hiervoor worden een heating coil (verwarmen) en peltier element (koelen) gebruikt. Het samplebed bevat ook een vacuum aansluiting die gebuikt kan worden om het sample stugger te bevestigen wanneer de gebruiker trillingsproblemen ondervind.

De functie van de isolatielaag is het isoleren van het samplebed en de dump cilinder om te voorkomen dat warmte vanuit de dumpcilinder teruglekt in het sampleblok (van belang tijdens koelen van het monster)

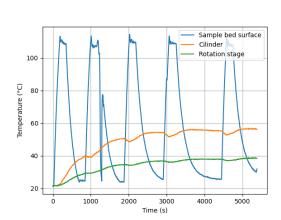


Figure 11: Temperature graph of the sample holder when simulating workload by heating to 110 degrees and cooling down to abient temperature (25 degrees) while waiting for 120 seconds when the level is reached

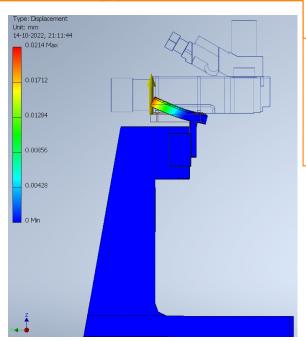


Figure 12: CAD schematic of the sample holder. By R. Stoelwinder. The sample holder prototype consists of 4 major parts. 1. The sample bed, wich contains a heating coil, peltier element, thermocouple and PT100 sensor. 2. The sample isolation layer. This is a shroud fabricated out of PEEK

CAD van

keuze voor peel

en mica

onderbouwen

CAD

schema

van de sample

holder in voegen

ref naar
optosigma

voegen

stage in

invoegen

4.4 Base stage automisation

for this project the base xy stage () has to be automated, this will developed in house in collaboration with LION FMD and ELD.

The stages were automated using NEMA17 stepper motors, and optical endstops. The stepper motors and endstops are controlled by the controller developed by ELD. The contents and used tecniques in the controll box are out of the scope for this report.

The first prototype bracket makes it possible to test the complete system and work out implementation bugs. It is recommended to create further iterations of the brackes as the current version can flex $\pm 3mm$ and this has a detremental effect on the rigidity of the base xy stage, this because the stages are held in place by the stepper motor. Furthermore it is also recommended to replace the ball bearings in the spindles as these

were damaged during fabrication and the spindle is now only held in place by the stepper motor

4.5 Stage calibration

Due to the mchanisms used in some of the actuators it is not possible to calibrate all the staged, nor is this needed for the application. The stages that cannot be calibrated are the x, y, and z axis of the mask due to the used slip-stick mechanism (see figure 10).

The slip stick mechanism makes it possible to use piezo actuators with high resolution for an unbound range. The drawback is that due to the slip stick mechanism (friction based) the actuator has a position uncertainty of and a sstep uncertainty of .

4.6 Software

Because one of the main criteria of the project is flexibility and modularity this has to be taken in consideration from the beginning. This means the project needs to be created in a structured and standardised way using design patterns and a modular architecture (see appendix A for the definition of these terms).

4.6.1 Architecture

As a main architecture a web application inspired framework is used. This means that the system consist of three major components: Frontend, Middleware and backend (for more information about these definitions see appendix A). Using standard design patterns makes getting to know the code and editing it less cumbersome and error prone for future developers. An overview of the system flow can be seen in figure 13

4.6.2 Frontend

The frontend is the part of the system that is visible to the user. This part of the system is responsible for the user interface and the communication with the middleware. The system has two pre made interface options: GUI and TUI. For operators of the system it is recommended to use the GUI as no knowledge of the command set is needed and safety features like thermal-runaway and forbidden areas are enabled. For developers it is recommended to use the TUI as it is more flexible and allows for more control over the system.

The GUI is created using QT6 with Pyside6 bindings to ensure interoperability between different operating systems and detailed documentation for future developers.

The TUI consists of a simple loop that pushes the gcode commands to the backend and uses a thread to monitor the backend response.

4.6.3 Middleware

The middleware is a method that can be used to communicate between the frond and backend. The middleware base class (see B) contains all the base methods needed for the system to work with a middleware method. The system contains two default middleware methods: The processing pipe, wich is used for when the backend runs on the same computer as the frondend but on a seperate core (it is strongly discuraged to run the backend on the same core as the frondend as this makes the backend behavoir depend on core workload.) The second method is the serial method and is based on the PySerial library and is used when the backend runs a differend computer than the frondend. The serial middleware method can be easily adapted to work with wireless serial communication but this is dicuraged as this method is more prone to errors.

positie uncertainty in voegen

step variatie invo

laatste pi jlen in de correcte richting zetten

citation invoegen

citation invoegen

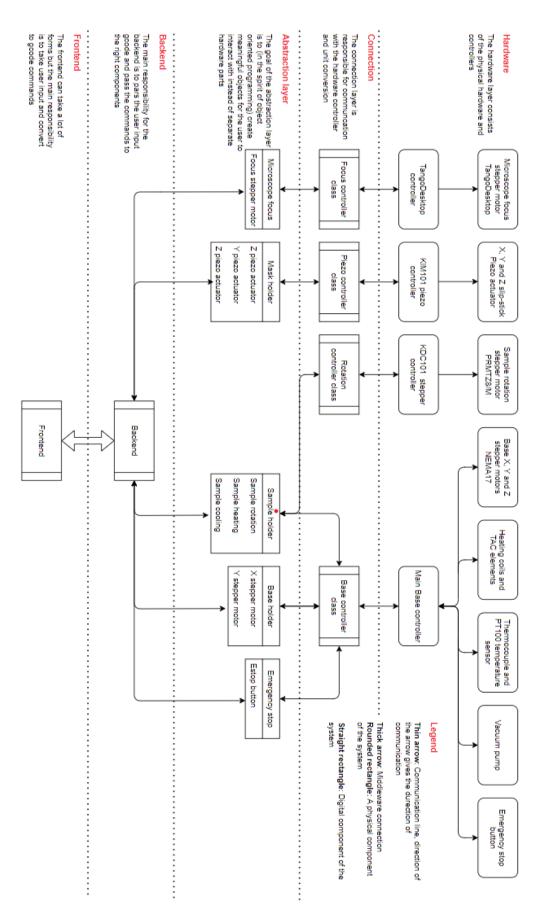


Figure 13: Software flow of the project.

4.6.4 Backend

The backend is the part of the system that is responsible for the communication with the hardware and the middleware and managed the object the user can interact with (sample holder, mask holder, etc.) The backend accepts all classes that inherit from their respective base class and abide the programming guidelines

Due to time constraints it was not possible to develop the backend to run on unix based systems

18

naar doc

referentie

stukje over FTD issue

stukje over voordeel

van runnen op IO controlle

toevoege

4.6.5 Forbidden areas

To prevent the system from damaging itself or the sample it is important to prevent the system from moving to certain areas in certain states.

Phase space variables (system attributes):

- Position of all the axis*
- · Velocity of all the axis
- · Acceleration of all the axix
- · Sample temperature
- · Sample heating and cooling ramp

This means the phase space will consist of 21 dimensions, where each dimension reperesents the current value of a system attribute.

First the phase space is bordered off by the hardware limitations like maximum velocity, minmal reproducable step size, range, etc. Further forbidden areas are studied using a fractional factorial design to determine the most important variables that influence the system.

The forbidden areas will be determined using a fractional factorial design with the following parameters (see excel file)

- 5 Conclusion
- 6 Discussion

References

- DVIA-T Tabletop Active Vibration Isolation Platform | Products. URL https://www.daeilsys.com/products/active-vibration-isolation-systems/tabletop-active-vibration-isolation-platform/.
- A. K. Geim and I. V. Grigorieva. Van der Waals heterostructures. 499(7459):419–425. ISSN 1476-4687. doi: 10.1038/nature12385. URL https://www.nature.com/articles/nature12385.
- M. Hesselberth. Basic calculations for vibration isolators. a.
- M. Hesselberth. Microscopie in beweging. b.
- M. K. V. Isolation. Vibration Criterion (VC) curves | Minus K. URL https://www.minusk.com/content/technology/vc_curves_minus_k_vibration_isolation.html.
- S. Mazerolle, R. Rabe, T. Varidel, and J.-M. Breguet. Positioning, Handling and Measuring inside a Scanning Electron Microscope.

A Programming terms

Design patterns

In programming, a design pattern is a general repeatable solution to a commonly occurring problem in software design. A design pattern is not a finished design that can be transformed directly into code. It is a description or template for how to solve a problem that can be used in many different situations.

Design patterns are used to describe solutions to specific design problems in object-oriented programming. They provide a way to reuse successful designs and design solutions that have been proven to work well in the past.

There are many different types of design patterns, including creational patterns, structural patterns, and behavioral patterns. Creational patterns deal with object creation mechanisms, trying to create objects in a manner suitable to the situation. Structural patterns deal with object composition, creating relationships between objects to form larger structures. Behavioral patterns focus on communication between objects, what goes on between objects and how they operate together.

Using design patterns can make it easier to design and develop software, because they provide a common vocabulary and framework for thinking about and solving design problems. They also help to make code more maintainable and scalable by providing a clear, consistent way to structure and organize it.

Modular architecture

In a web application or system, the frontend refers to the part of the application that the user interacts with, typically through a web browser. It includes all the elements that the user can see and interact with, such as the layout, user interface, and visual design of the application.

The backend, on the other hand, refers to the part of the application that handles the logic and processing behind the scenes. It is responsible for tasks such as storing and retrieving data from a database, performing calculations and processing, and interacting with other systems or APIs.

Middleware is software that sits between the frontend and the backend and helps to facilitate communication and data exchange between them. It can provide functions such as authentication, routing, and data transformation, and can help to abstract away some of the complexity of the backend from the frontend.

In a web application, the frontend and backend are typically implemented using different technologies and run on different servers or infrastructure. Middleware can be implemented using a variety of technologies, depending on the specific requirements of the application.

Multi-threading and processing

In computer science, multi-threading is a technique that allows a single process or program to have multiple threads of execution. A thread is a separate flow of execution within a process, and each thread can run

concurrently or in parallel with the other threads within the same process.

Multi-threading can be used to improve the performance of a program by allowing it to perform multiple tasks concurrently. For example, a program that has a user interface and needs to perform some time-consuming calculations in the background could use multi-threading to allow the user to continue interacting with the interface while the calculations are being performed.

Multi-processing is a technique that allows a computer to run multiple processes simultaneously. A process is an instance of a program that is being executed by the operating system. Each process has its own memory space and runs in a separate environment, and multiple processes can be run concurrently on different cores or processors within a computer.

Multi-processing can be used to improve the performance of a program by allowing it to take advantage of multiple processors or cores within a computer. This can be particularly useful for programs that need to perform a lot of calculations or that are designed to run on a distributed system with multiple machines.

B Backend base classes

The base classes are used as a template for new components. The base classes contain all the functions that are required for the component to work with the rest of the system. Notice that two different errors can be raised: NotImplementedError and NotSupportedError. The functions that raise a NotImplementedError should always be implemented for the component to work correctly with the rest of the system. It is safe to raise NotSupportedError as these are caught and handled by the system.

Harware base class

```
class NotSupportedError(Exception):
1
       """Exception raised when a method is not supported."""
2
3
4
       def __init__(self, msg=None):
           """Initialize the exception."""
5
6
           self._msg = msg
7
       def __str__(self):
8
9
           return self._msg
10
11
12
   class HardwareNotConnectedError(Exception):
13
       """Exception raised when a hardware is not connected."""
14
       def __init__(self, msg=None):
15
           """Initialize the exception."""
16
17
           self._msg = msg
18
19
       def __str__(self):
20
           return self._msg
21
22
   class NotCalibratedError(Exception):
23
24
25
       Exception raised when the hardware is not calibrated for the asked function.
26
       F.e. trying to do an absolute move when the home point is unknown.
27
28
29
30
       def __init__(self, msg=None):
           """Initialize the exception."""
31
32
           self._msg = msg
33
34
       def __str__(self):
35
           return self._msg
36
37
   class HardwareError(Exception):
38
       """General exception raised when the hardware is not working properly."""
39
40
41
       def __init__(self, msg=None):
           """Initialize the exception."""
42
43
           self._msg = msg
44
       def __str__(self):
45
           return self._msg
46
47
48
49
  class Base:
```

```
50
        Base class for hardware.
51
52
       This class contains all the functions the StackingSetupBackend class expects
53
54
        connected hardware to have. Functions that are supported should be overridden
        in the derived class.
55
56
57
        .. important::
            Functions that should be supported by all hardware raise a 'NotImplementedE:
58
            optional functions raise ''NotSupportedError''. The ''NotSupportedError'' is
59
            by the ''StackingSetupBackend()'' class, so it is safe to raise it in functi
60
            not supported by all hardware.
61
62
        .. note:: Each function should return an exit code (0 for success, 1 for failure
63
64
            and an error message, str, or None.
65
        0.00
66
67
        _id = None
68
        _type = "HARDWARE BASE CLASS"
69
70
       # COMPONENT LIMITS
71
72
        _max_speed = None
        _max_acceleration = None
73
74
        _max_temperature = None
75
76
        # ATTRIBUTES
77
        @property
78
        def id(self):
            """Get the class identifier."""
79
80
            return self._id
81
        @property
82
        def type(self):
83
84
            """Get the type of the hardware."""
85
            return self._type
86
87
        @property
        def device_info(self):
88
89
            """Get the device info of the hardware."""
90
            raise NotImplementedError()
91
       # STEP CALIBRATION ATTRIBUTES
92
93
94
        If the connected component can move only one of the steps per ... should be supp
        If the component cannot move none have to be supported.
95
96
97
98
        @property
        def steps_per_um(self):
99
100
            """Get the steps per um of the hardware."""
101
            raise NotSupportedError()
102
        @property
103
        def steps_per_deg(self):
104
            """Get the steps per degree of the hardware."""
105
106
            raise NotSupportedError()
107
108
        # MOVEMENT PROFILE ATTRIBUTES
109
        @property
110
        def position(self):
            """Get the position of the hardware."""
111
```

```
112
            raise NotSupportedError()
113
114
        @property
        def speed(self):
115
            """Get the set speed of the hardware in um/s or deg/s."""
116
117
            raise NotSupportedError()
118
119
        Ospeed.setter
120
        def speed(self, speed):
121
            """Set the speed of the hardware in um/s or deg/s."""
122
            raise NotSupportedError()
123
124
        @property
125
        def acceleration(self):
            """Get the acceleration of the hardware."""
126
127
            raise NotSupportedError()
128
129
        @acceleration.setter
        def acceleration(self, acceleration):
130
            """Set the acceleration of the hardware."""
131
132
            raise NotSupportedError()
133
        # TEMPERATURE ATTRIBUTES
134
135
        @property
136
        def temperature(self):
137
            """Get the temperature of the hardware."""
138
            raise NotSupportedError()
139
140
        @property
141
        def target_temperature(self):
142
            """Get the target temperature of the hardware."""
143
            raise NotSupportedError()
144
145
        @target_temperature.setter
146
        def target_temperature(self, temperature):
            """Set the target temperature of the hardware."""
147
            raise NotSupportedError()
148
149
        # CONNECTION FUNCTIONS
150
151
        def connect(self):
            """Connect the hardware."""
152
153
            raise NotImplementedError()
154
        def disconnect(self):
155
            """Disconnect the hardware."""
156
157
            raise NotImplementedError()
158
159
        # STATUS FUNCTIONS
        def is_connected(self):
160
161
            """Check if the hardware is connected."""
162
            raise NotImplementedError()
163
164
        def is_moving(self):
            """Check if the hardware is moving."""
165
            raise NotSupportedError()
166
167
168
        def is_homed(self):
169
            """Check if the hardware is homed."""
170
            raise NotSupportedError()
171
172
        def get_status(self):
            """Give a status report."""
173
```

```
raise NotImplementedError()
174
175
176
        # HOMING FUNCTIONS
177
        def home(self):
            """Home the hardware."""
178
179
            raise NotSupportedError()
180
181
        # MOVING FUNCTIONS
182
        def start_jog(self, direction):
            """Start a jog in a direction."""
183
184
            raise NotSupportedError()
185
186
        def stop_jog(self):
            """Stop a jog."""
187
188
            raise NotSupportedError()
189
        def move_to(self, position):
190
            """Move the hardware to a position."""
191
192
            raise NotSupportedError()
193
194
        def move_by(self, position):
            """Move the hardware by a position."""
195
196
            raise NotSupportedError()
197
198
        def rotate_to(self, rotation):
199
            """Rotate the hardware to a position."""
200
            raise NotSupportedError()
201
202
        def rotate_by(self, rotation):
            """Rotate the hardware by a position."""
203
204
            raise NotSupportedError()
205
        def stop(self):
206
            """Unconditionally stop the hardware."""
207
208
            raise NotImplementedError()
209
        def emergency_stop(self):
210
            """Unconditionally stop the hardware."""
211
212
            raise NotImplementedError()
```

Middleware base class

```
import configparser
1
2
   import time
3
   SENTINEL = "SENTINEL" # Sentinel command to close the pipe
4
   EOM_CHAR = "EOM" # String indicating the end of a message over a pipe
5
6
7
   class HandshakeError(Exception):
8
9
       def __init__(self, message=None):
10
           self._message = message
11
12
       def __str__(self):
13
           return self._message
14
15
   class BaseConnector:
16
       0.00
17
       Class to hold all the expected connection functions.
18
19
       This class does not manage the connection it is a base class that should
20
21
       be inherited.
       0.00
22
23
24
       _connection_method = None
       _role = None
25
26
       _handshake_complete = False
27
       _SENTINEL = SENTINEL
28
       # ATTRIBUTES
29
30
       @property
31
       def connection_method(self):
           """Return the connection method."""
32
           return self._connection_method
33
34
35
       @property
36
       def role(self):
37
           """Return the role of the connection."""
38
           return self._role
39
40
       @property
       def handshake_complete(self):
41
           """Return the handshake status."""
42
           return self._handshake_complete
43
44
45
       @property
46
       def is_connected(self):
           """Check if the device is connected."""
47
48
           raise NotImplementedError()
49
50
       @property
51
       def SENTINEL(self):
            """Return the sentinel command."""
52
           return self._SENTINEL
53
54
55
       # METHODS
       def connect(self):
56
           """Connect to the device."""
57
58
           raise NotImplementedError()
59
       def disconnect(self):
60
```

```
"""Disconnect from the device."""
61
            raise NotImplementedError()
62
63
        def send_sentinel(self):
64
65
            """Send a sentinel to the IO controller (RPI)."""
            raise NotImplementedError()
66
67
        def send(self, command):
68
            """Send a command to the device."""
69
70
            raise NotImplementedError()
71
        def message_waiting(self):
72
            """Check if a message is waiting."""
73
            raise NotImplementedError()
74
75
76
        def receive(self):
            """Receive data from the device."""
77
            raise NotImplementedError()
78
79
        def handshake(self):
80
81
            # Depending on the role of the connector decide
            # what to send and what to receive
82
            if self._role == "FRONDEND":
83
84
                self._frondend_handshake()
85
                self._handshake_complete = True
86
87
                # Empty the buffer
88
                while self.message_waiting():
89
                     _ = self.receive()
90
91
            elif self._role == "BACKEND":
92
                self._backend_handshake()
93
                self._handshake_complete = True
94
                # Empty the buffer
95
                while self.message_waiting():
96
                     _ = self.receive()
97
98
            else:
99
100
                raise HandshakeError("Unknown role {}".format(self._role))
101
102
        def _frondend_handshake(self):
            if not self.is_connected:
103
                return False
104
            # Wait for the response
105
106
            while True:
107
                # Send the hello message
108
                self.send("Hello there.")
109
                if self.message_waiting():
110
111
                     res = self.receive()
112
                else:
113
                     continue
114
                if res[0] == "Hello there general Kenobi.":
115
                     return True
116
117
                else:
118
                     raise ValueError("Unexpected message: {}".format(res[0]))
119
            raise ValueError("frondend Handshake failed")
120
121
       def _backend_handshake(self):
122
```

```
\mbox{\tt \#} Wait for the hello message
123
124
            while True:
125
                 time.sleep(0.1)
126
127
                 if self.message_waiting():
                     res = self.receive()
128
129
                 else:
                     continue
130
131
                 if res[0] == "Hello there.":
132
                     self.send("Hello there general Kenobi.")
133
134
135
                 else:
                    raise ValueError("Unexpected message: {}".format(res[0]))
136
```

Todo list

Add the foreword	ii
Create the abstract	iii
pagina nummering pas hier beginnen, voorgaande in romeinse nummering	v
Rephrase the text so it isn't flagged as plagiaat	1
citaat invoegen	3
afbeelding van grafeen en hexagonaal boornitride invoegen	3
Stuk invoegen over verandering in fase plot (bode) bij verschillende massa, hoe hoger de massa hoe	
verder de fase drop naar beneden schuift, alles boven de grens heeft geen onvloed op de opstelling	3
Grafiek maken van harmonische response over tijd van de gemaakte overdrachtsfunctie (zou alleen	
bij lage f met hoge A in trilling moeten komen	3
Aantonen dat een hoge dichtheid (en dus massa) de resonantie frequentie verhogen	4
uitzoeken aan welke vc norm wij willen voldoen	5
betekenis van NIST-A norm uitzoeken	5
Verwijzen naar verwachte trillingen grafiek	5
CAD schema van de mask holder invoegen	7
keuze voor peek en mica onderbouwen	8
CAD schema van de sample holder invoegen	8
CAD van bracket invoegen	8
ref naar optosigma stage invoegen	8
citation invoegen	8
positie uncertainty invoegen	9
step variatie invoegen	9
laatste pijlen in de correcte richting zetten	9
citation invoegen	9
citation invoegen	9
referentie naar docs toevoegen	11
stukje over FTDI issue tovoegen	11
stukie over voordeel van runnen on IO controller toevoegen	11